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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/503,638	02/14/2000	Kirk D. Prall	MICR131.02	6942	
75	90 02/12/2003				
Steven R. Ormiston Ormiston & McKinney, PLLC 802 W. Bannock Street, Ste. 400 P.O. Box 298			EXAMINER		
			PERALTA, GINETTE		
Boise, ID 8370)1		ART UNIT	PAPER NUMBER	
			2814		
			DATE MAII ED: 02/12/2003		

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	plicant(s)	
	09/503,638	PRALL ET AL.	
, Advisory Action		Art Unit	T
•	Examiner Ginette Peralta	2814	
The MAILING DATE of this communication app		i —	dress
The MAILING DATE of this communication app	gears on the cover shoot with a	NOTION FOR ALLO	MANCE
THE REPLY FILED 27 January 2003 FAILS TO PLACE Therefore, further action by the applicant is required to inal rejection under 37 CFR 1.113 may only be either: condition for allowance; (2) a timely filed Notice of AppExamination (RCE) in compliance with 37 CFR 1.114.	(1) a timely filed amendment peal (with appeal fee); or (3) a	which places the appl timely filed Request f	lication in or Continued
	REPLY [check either a)-or b)]_		
a) The period for reply expiresmonths from the mailing	g date of the final rejection.	in the final rejection, whiche	ver is later. In no
a) In the period for reply expires	AS FILED WITHIN TWO MONTHS OF	THE FINAL REJECTION.	See MPEP
706.07(f). Extensions of time may be obtained under 37 CFR 1.136(a). The nave been filed is the date for purposes of determining the period of ext 37 CFR 1.17(a) is calculated from: (1) the expiration date of the shorter (b) above, if checked. Any reply received by the Office later than three earned patent term adjustment. See 37 CFR 1.704(b).	ned statutory period for reply originally s months after the mailing date of the fin	set in the final Office action; of all rejection, even if timely file	or (2) as set forth in
1. A Notice of Appeal was filed on Appella 37 CFR 1.192(a), or any extension thereof (37 CFR 1.192(a)).	nt's Brief must be filed within t CFR 1.191(d)), to avoid dismis	the period set forth in sal of the appeal.	
2. The proposed amendment(s) will not be entered	d because:		
(a) they raise new issues that would require fu	rther consideration and/or sea	rch (see NOTE below) ;
(b) They raise the issue of new matter (see Not	te below);		
(c) they are not deemed to place the application issues for appeal; and/or	on in better form for appeal by		
(d) they present additional claims without can	celing a corresponding number	er of finally rejected cl	aims.
NOTE:			
3. Applicant's reply has overcome the following re-	jection(s):		
4. Newly proposed or amended claim(s) wo canceling the non-allowable claim(s).			
5.⊠ The a) affidavit, b) exhibit, or c) reques application in condition for allowance because	: See Continuation Sneet.		
6. The affidavit or exhibit will NOT be considered raised by the Examiner in the final rejection.			
7. For purposes of Appeal, the proposed amendment explanation of how the new or amended claim	nent(s) a)⊡ will not be entered s would be rejected is provide	d or b)∐ will be enterd d below or appended.	ed and an
The status of the claim(s) is (or will be) as follo	ws:		
Claim(s) allowed:			
Claim(s) objected to:			
Claim(s) rejected: <u>23-28,30-33</u> .			
Claim(s) withdrawn from consideration:			/
8. The proposed drawing correction filed on	_ is a)□ approved or b)□	disapproved by the Ex	kaminér.
9. Note the attached Information Disclosure State	ement(s)(PTO-1449) Paper N	o(s)	\angle
	(n) (d)	21 Magazin	

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Continuation Sheet (PTO-303) 09/503,638

Continuation of 5. does NOT place the application in condition for allowance because: Regarding applicant's argument that the examiner incorrectly asserts that Katayama "teaches the formation of the second impurity region by both diffusion and implantation, and that only one of the implants is in the contact region, it is noted that in Fig. 36, Katayama teaches two implant regions 103b and 104 contacting the capacitor lower electrode.